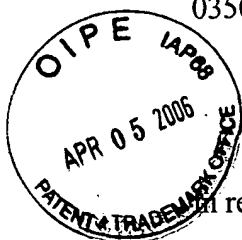


IFW

03500.017772

PATENT APPLICATION



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Application of:)	
	:	Examiner: Not Yet Assigned
TOHRU DEN ET AL.)	
	:	Group Art Unit: 2812
Application No.: 10/533,565)	
	:	
Int'l Application No. PCT/JP03/15948)	
	:	
Filed: December 12, 2003)	
	:	
For: NANOSTRUCTURE,)	
ELECTRONIC DEVICE AND	:	
METHOD FOR)	
MANUFACTURING THE SAME	:	April 4, 2006

Mail Stop PCT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SECOND INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Since the U.S. Patent and Trademark Office waived the requirement under 37 C.F.R. § 1.98 (a)(2)(I) for submitting a copy of each cited U.S. patent and each U.S. patent application publication for all U.S. national patent applications and for all international applications that have entered the national stage under 35 U.S.C. § 371, no copies of such documents are enclosed.

Copies of the other documents are enclosed.

In addition, the Examiner's attention is directed to the following U.S. Patent Application:

APPLICATION NO.

10/538,127

FILING DATE

December 12, 2003

GROUP ART UNIT

2879

Since it is Applicants' understanding that this application is stored in the U.S. Patent and Trademark Office's IFW system, a copy thereof is not enclosed due to a *sua sponte* waiver of 37 C.F.R. § 1.98(a)(2)(iii).


The concise explanation of relevance for the non-English document may be found, *inter alia*, in the English language abstract attached thereto, in the specification where it is cited and/or in U.S. Patent No. 5,997,958, which is in the same patent family.

CONCLUSION

It is respectfully requested that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

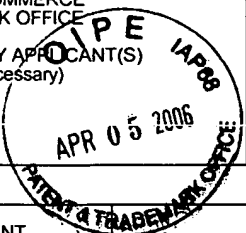
Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our address given below.

Respectfully submitted,



Jason M. Okun
Attorney for Applicants
Registration No.: 48,512

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FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary)				ATTY DOCKET NO. 03500.017772		APPLICATION NO. 10/533,565	
				APPLICANT Tohru Den et al.			
				FILING DATE December 12, 2003		GROUP 2812	
U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		5,997,958	12/07/99	Sato et al.	427	468	
		2004/0043208 A1	03/04/04	Fukutani et al.	428	304.4	
		2004/0033339 A1	02/19/04	Fukutani et al.	428	137	
		2006/0032526 A1	02/16/06	Fukutani et al.	136	205	
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT
	WO	2004/054924 A1	07/01/04	International			
	JP	10-321834	12/04/98	Japan			Abstract
OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)							
		R.C. Furneaux et al., "The Formation of Controlled-Porosity Membranes from Anodically Oxidized Aluminum," 337 Nature 147-49 (January 1989).					
EXAMINER				DATE CONSIDERED			

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Sheet 1 of 1